

REMARKS

Applicants thank the Examiner for the courtesy extended to Applicants' attorney during the interview held January 23, 2007, in the above-identified application. During the interview, Applicants' attorney explained the presently-claimed invention and why it is patentable over the applied prior art, and discussed other issues raised in the Office Action. The discussion is summarized and expanded upon below.

The rejection of Claims 1, 2, 5-10 and 13-15 under 35 U.S.C. § 102(e) as anticipated by or, in the alternative, under 35 U.S.C. § 103(a) as obvious over, US 2005/0042538 (Babich et al), is respectfully traversed. Babich et al has a § 102(e) date of August 22, 2003. **Submitted herewith** is a certified English translation of Applicants' Japanese Priority Application JP 2002-354512, filed December 6, 2002. Applicants respectfully request that the Examiner find that Applicants are entitled to the filing date of their priority application under 35 U.S.C. § 119. Accordingly, it is respectfully requested that this rejection be withdrawn.

The rejection of Claims 1, 2 and 5-12 under 35 U.S.C. § 102(e) as anticipated by or, in the alternative, under 35 U.S.C. § 103(a) as obvious over, US 2004/024789 (Apen et al), is respectfully traversed. Apen et al is drawn to a composition comprising a (a) thermosetting component having a particular monomeric structure, and (b) an adhesion promoter [0013]-[0015]. The monomer may be, for example, an Si-containing compound containing a -C≡C- group, as shown in Figure 1C therein [0069]. The adhesion promoter is preferably a polycarbosilane having a formula (I) therein [0017]-[0019].

Apen et al neither anticipates nor otherwise suggests the presently-claimed invention. With regard to the polycarbosilane therein, and as Applicants' attorney pointed out during the above-referenced interview, none of the groups bonding individual Si atoms contain a

-C $\equiv$ C-group. With regard to the thermosetting component, and as Applicants' attorney noted during the interview, polymerization to form it comprises a chemical reaction of the ethynyl group [0041]. Thus, the thermosetting component in Apen et al will not be a carbosilane meeting the terms of present formula (1), wherein the -C $\equiv$ C- groups do not participate in a thermosetting reaction.

For all the above reasons, it is respectfully requested that this rejection be withdrawn.

The provisional rejection of Claims 1, 2, 8 and 9 on the ground of non-statutory obviousness-type double patenting over Claims 1, 9-14 and 16 of Copending Application No. 10/726,592 (copending application), is respectfully traversed. The claims of the copending application do not disclose or suggest the presently-claimed insulation film. Accordingly, it is respectfully requested that this provisional rejection be withdrawn.

The rejection of Claims 1, 2 and 5-15 under 35 U.S.C. § 112, second paragraph, is respectfully traversed. Indeed, the rejection would now appear to be moot in view of the above-discussed amendment. Accordingly, it is respectfully requested that the rejection be withdrawn.

Applicants **again** respectfully call the Examiner's attention to the Information Disclosure Statement (IDS) filed June 21, 2005. The Examiner is respectfully requested to initial the Form PTO 1449 submitted therewith, and include a copy thereof with the next Office communication. A copy of said Form is **attached herewith**.

Moreover, since the date of the IDS is before the date of the Office Action and thus technically was part of the Official file as of the Office Action date, Applicants respectfully request that should the Examiner determine that a new ground of rejection needs to be made in the next Office Action relying in whole or in part on any of the references cited in the IDS, then said next Office Action not be made Final, even if the new rejection was necessitated by the present amendment to the claims.

Applicants respectfully submit that all of the presently-pending claims in this application are now in immediate condition for allowance. Accordingly, the Examiner is respectfully requested to pass this application to issue.

Respectfully submitted,

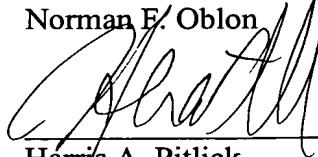
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